Imaging Techniques for Transverse Profile/Size Monitors

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- I. Introduction
- II. Beam profiling with YAG:Ce scintillation
 - Scintillator resolution
 - Depth-of-focus issue

III. Optical Transition Radiation (OTR)

- OTR basics
- OTR point-spread-function (PSF) aspects
- Microbunching instability and coherent OTR (COTR)
- Nonrelativistic beams
- IV. Future tests
- V. Summary





- The charged-particle beam transverse size and profiles are part of the basic characterizations needed in accelerators to determine beam quality, e.g. transverse emittance.
- A basic beam imaging system includes:
 - conversion mechanism (scintillator, optical or x-ray synchrotron radiation (OSR or XSR), Cherenkov radiation (CR), optical transition radiation (OTR), undulator radiation (UR), and optical diffraction radiation (ODR).
 - optical transport (lenses, mirrors, filters, polarizers).
 - imaging sensor such as CCD,CID, CMOS camera, with or without intensifier and/or cooling
 - video digitizer
 - image processing software





System related

- YAG:Ce powder and crystal screen spatial resolution.
- Camera resolution and depth of focus.
- OTR polarization effects and OTR point spread function.
- Camera calibration factor.
- Finite slit size (if applicable).

Accelerator / beam related

- Beta star term in spectrometers.
- Macropulse blurring effects on energy spread , beam size, and beam divergence in OTR images.
- Most of the examples will be for electrons.





- Uncorrelated terms are treated as a quadrature sum to actual image size Act (see Lyons' textbook ^a).
 - Observed image size Obs
 - YAG screen effects YAG
 - Camera resolution Cam
 - Finite slit width Slit
- In addition there can be macropulse effects and OTR polarization effects.

$$Obs^2 = Act^2 + YAG^2 + Cam^2 + Slit^2$$

and solving for the actual beam size we have,

$$Act = \sqrt{Obs^2 - YAG^2 - Cam^2 - Slit^2}$$

^aLouis Lyons, Statistics for Nuclear and Particle Physicists (1986)





	YAG:Ce (Cerium doped) powder or single crystal	OTR screen, e.g. Al or aluminized Si
Efficiency	~100x	1x
Spatial resolution	Volume effect, grain size	EM surface phenomenon
Spectral content	Narrow band (~20 nm)	Broad band
Saturation, non-linearities	at high beam intensities	no
Response time	~50 – 100 nsec	~10 fsec (skin depth)
Screen geometry: normal / angular (45 ⁰)	depth of focus, scattering, er system simplicity, etc.	ffective thickness,
Screen thickness, energy deposition, beam scattering	100 µm range	minimum: 1 µm (fragile!) maximum: some 100 µm
Light scattering	Halo effects through scintillating volume	None





- YAG:Ce screens, used at the A0 Photoinjector:
 - The screens have nominally a 5-µm grain size and are coated at 50-µm thickness on various metal substrates.
 - Substrates are AI or SS and 1 mm thick.
 - In the A0PI arrangement the scintillator was on the front surface of the substrate, and oriented at 45^o to the beam direction.
 - Powder screens are kindly provided by *Klaus Floettmann* (DESY).

Observed Characteristics

- The response time is about 80 ns FWHM.
- There have been reports of saturation of the mechanism for incident electron beam areal charge densities ~10 fC/μm².
 - This effect can cause a charge dependence of the observed image size in addition to the low-charge, screen resolution limit.





Beamline and diagnostics support for EEX applications







	# of bunches	X5 linear polarization	Fit σ (pixel)	X Size (µm)
OTR	10	none	5.49 ± 0.05	124.5
		vertical	4.47 ± 0.09	101.0
YAG:Ce	1	none	5.67 ± 0.05	128.7
		vertical	5.71 ± 0.04	129.6

- Both screen surfaces at 45^o to the beam direction.
- Gaussian fits to the projected beam profiles of 10 images.
- Deduced YAG resolution term (page 6): 80 \pm 20 μ m
- Other data sets averaged for YAG term: 60 \pm 20 μ m



• Scintillator screen resolution vs. thickness after applying corrections discussed on page 6.





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- Most data examples will be for electrons except one hadron case and one heavy-ion case.





- 1 mm (X5) / 4 mm (X24) spaced slits, 50 µm wide
 - Camera calibration ~30 µm / pixel.
- Depth-of-focus issues in extended field of view for 45^o arrangement of the YAG:Ce scintillator screen







 Application tool provides online emittance and C-S parameter calculations to facilitate operations.



A.H. Lumpkin BIW12 April 17, 2012



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BIW90

OTR FOIL

(OBJECT PLANE)

IMAGED

PATTERN

IMAGED





• OTR single particle spectral-angular distribution: $1^2 N = 2 - 1 = (\rho^2 + \rho^2)$

$$\frac{d N_1}{d\omega d\Omega} = \frac{e}{\hbar c} \frac{1}{\pi^2 \omega} \frac{(v_x + v_y)}{(\gamma^{-2} + \theta_x^2 + \theta_y^2)}$$

E = 220 MeV *σ*_{x', y'} = 0.2 mrad



 Ω spatial angle

- N_1 # of photons
- $\Theta_{x,y} \text{ radiation angle}$
- e, \hbar , c, π constants
- Coherent spectral-angular distribution from a macropulse

 $\frac{d^2 N}{d\omega d\Omega} = \left| r_{\perp, //} \right|^2 \frac{d^2 N_1}{d\omega d\Omega} I(\mathbf{k}) \mathfrak{I}(\mathbf{k})$

- N # of photons from per unit frequency and solid angle (typ. 1 e -> 0.001 photons)
- r reflection coefficient
- I interference function (double foil)
- F coherence function (can be non-linear)









Coherence Function

$$\mathfrak{I}(\mathbf{k}) = N + N_B (N_B - 1) |H(\mathbf{k})|^2$$

Fourier Transform of Charge Form Factors

$$H(\mathbf{k}) = \frac{\rho(\mathbf{k})}{Q} = g_x(k_x)g_y(k_y)F_z(k_z)$$

Q = total charge of macropulse

Bunching fraction = $f_B = N_B / N$

For the broadband microbunching

instability, enhancements can occur

at visible wavelengths, COTR.

Note: The coherence function reduces to just the number of particles, N, when the number of microbunched particles, N_B is zero. From D. Rule and A. Lumpkin, PAC'01





 New developed imaging station in collaboration with RadiaBeam, Inc.











Test of OTR Normal to Beam



Optics focused on crystal location:

gives superposition of focused OTR and defocused OTR source from mirror.







At the diffraction limit $\Delta x \approx \lambda / \Delta \theta$ the image of a point source radiates a ring pattern defined by the OTR point spread function (PSF): **PSF:** convolution integral of Source Lens Image $f^2(\theta_m, \gamma, \zeta) = \left[\int_0^{\infty} d\theta_m (\gamma, \zeta) - \int_0^{\infty} d\theta_m (\gamma, \zeta) \right]$ $(\zeta \theta) d\theta^2$ Ζ Point charge diffraction **OTR response** a _____ b _ stimulus function $\theta = R_i / a \qquad \varsigma = k R_i / M$ $- \theta_m$ maximum acceptance angle - M = b/a magnification factor $- R_i$ radius 0.0015 of the lens 5 0.001 Cross section Example: 5.10^{-4} M=1, E=4GeV, λ =500nm

 -2.10^{-5}

courtesy C. Liu (BNL)

 $2 \cdot 10^{-5}$

 1.10^{-5}

0

X position (um)



- 14.3 MeV, M=1, λ =500 nm, θ_{max} =0.010, sigma =25 μ m
- This version with convolutions implemented at FNAL.





• 14.3 MeV, M = 1, λ = 500nm, θ_{max} = 0.010, σ = 10 & 50 μ m



HorPol-HorProj PSF Sigma = NA HorPol-VerProj PSF Sigma = 16.63 µm Total PSF Sigma = 55.63 μm HorPol-HorProj PSF Sigma = 58.49 μm HorPol-VerProj PSF Sigma = 53.05 μm



- OTR Perpendicular component has 15 % smaller profile.
 - Beam measurements with a vertical stripe, ~50 μm wide.

Total Pol.: Left Single-Gaussian Fit $\sigma_1 = 66.8 \pm 0.3 \ \mu m$

Vert. Pol.: Right Single-Gaussian Fit $\sigma_1 = 55.1 \pm 1.1 \ \mu m$

12µm effect @ 55 µm

(Cal.: 5.3 µm/pixel)







- KEK staff used vertical polarizer and small beam to observe PSF and suggested potential use of structure.
 - Use PSF valley for profile measurements at the PSF limit.



Figure 3: CCD image of the OTR taken with linear polarizer and 500 nm optical filter (a) and two image projections: horizontal (b) and vertical (c).





$$f(x) = a + \frac{b}{1 + [c(x - \Delta x)]^4} \left[1 - e^{-2c^2\sigma^2} \cos[c(x - \Delta x)] \right] \quad (1)$$

where a, b, c, σ , and Δx are free parameters of the fit function, namely: a is the vertical offset of the distribution with respect to zero which included a constant background; b is the amplitude of the distribution; c is the distribution width; σ is the smoothing parameter dominantly defined by the beam size; and Δx is the horizontal offset of the distribution with respect to zero

A. Aryshev et al. IPAC10





Estimation of OTR/COTR spectral effect for LCLS case.





• Reduction of COTR effects with 400x40 nm BPF, but need more sensitive camera than 40dB analog CCD to see remaining OTR.





120-GeV Proton Beam OTR Images Obtained at FNAL (2007)



Proton beams for the neutrinos with the main injector (NuMI) target can be imaged in the transport line.



V.E Scarpine, A.H. Lumpkin





- Is there sufficient charge crossing the interface so OTR could be detectable? Use Q² and β² dependencies.
- Can the thin foil survive the areal charge density levels? (Beamline exit windows and stripper foils do).
- 120-GeV protons, up to 10¹³ in a batch in 1mm x 1mm spot on aluminized Kapton (7 μm). Screen survived 6 months in beam at Fermilab.
- Look at lobe angle like 80-keV electrons? Or other.
- Use ICCD, cooled CCD, or CMOS cameras to boost sensitivity to low signals.
- Use Forward OTR; with annular mirror? Out of stripper foil?
- What beam intensity levels used at GSI, LHC, RHIC?



- Consider applying technologies and concepts for ions.
- Take advantage of charge state for OTR generation.





• Table I. Comparison of various particle beam cases and estimated OTR photons generated (Preliminary).

<u>Part.</u>	<u>E(MeV)</u>	<u>Q</u>	<u>β</u>	<u> </u>	<u>Y(ph/e)</u>	<u>N</u>	<u>Mult.</u>	Photon a	<u> # CCD</u>
e-	.080	1	0.65	1.15	2x10 ⁻⁶	4x10 ¹	¹ 1	7x10 ⁵	Int.
e-	150	1	0.99	300	10 ⁻³	6x10 ^g) _	6x10 ⁶	CCD
p+	120x10 ³	1	0.99	129	10 ⁻³	1 0 ¹¹	-	10 ⁸	CID
	MeV/u								
Ar	11.4	10	0.15	1.01	10 -6	10 ¹⁰	5.3	5x10 ⁴	*Int.
U	11.4	28	0.15	1.01	10 ⁻⁶	1 0 ¹¹	42	4x10 ⁶	*Int.
U	300	73	0.65	1.21	10 ⁻⁶	10 ⁹	5329	5x10 ⁶	*Int.

*Use intensifier for gain and the gating feature. More discussions later today. Also the ion intensity increases projected for FAIR look even better for photon numbers. The Multiplier (Mult.) column is the scaling with $Q^2\beta^2$.





Experimental setup consists of an OTR target ladder (6 targets on one ladder) and image-intensified CCD camera system (ICCD) from PROXITRONIC.



- the exact ICCD gating feature (down to 10 µs) was used to select preferentially the prompt OTR signal versus any background sources in the scene.
 - *GSI slides provided by B. Walasek-Hohne

Target ladder before high current irradiation



Target ladder after high current irradiation



For future investigations we reduced beam current!









Light yield versus particles per pulse

OTR light yield scales linearly with particle number



*GSI slide provided by B. Walasek-Hohne



• New parameter space for OTR/ODR tests provided at FACET.

Parameter	<u>APS</u>	<u>CEBAF</u>	<u>ILC</u>	<u>FACET</u>
Energy (GeV)	7	1-5	5,15,250	23
X Beam size (μm) Y Beam size (μm)	1300 200	80-100 80-100	300,150,3 15,8,2	30 10 10
Current (nA)	6	100,000	50,000	30
Charge/ 33 ms (nC)	3	3,000	10,000	3

• FACET parameters closer to ILC parameters.



Injector being installed with First beam expected in 2012.



and Saclay) installed in NML

Courtesy of M. Church

DESY) installed at NML.





- Scintillator resolution terms should be characterized,
 - Use normal incidence of beam as preferred geometry to minimize depth-of-focus issues in beam images.
- OTR polarization effects need to be elucidated
 - Plan to optimize OTR PSF and optical resolution.
 - Plan to use linear polarizers with OTR imaging for the perpendicular profile components at ASTA.
- Mitigate microbunching instability effects for profiling of bright beams.
 - Plan to use 400x40 nm band pass filters and LYSO:Ce crystals after bunch compression at ASTA to suppress expected diagnostics complications due to COTR.
- New paradigm for heavy-ion beam imaging with OTR.
- The future remains bright for imaging techniques.



- At left, schematic of ODR generated from two vertical planes (based on Fig.1 of Fiorito and Rule, NIM B173, 67 (2001). We started with a single plane.
- At right, calculation of the ODR light generated by a 7-GeV electron beam for d =1.25 mm in the optical near field based on a model (Rule and Lumpkin).





7-GeV Test at APS





Lumpkin et al., PRST-AB (Feb. 2007)





Vertical polarization component, lambda= 800 nm, IP= 100, 50 μm. Curves for 10, 20, 35, 50,100 μm.





• Path to test near-field imaging on 10-µm size at 23 GeV.



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